





	5	4	3	2	1
				REV. DATE DCN #   V1 08 Feb. 2011 E110008	
					D
L		2.25			—
	-	2.23			
_	090 <sup>+.000</sup> 002		2X .03 X 45.0		C
					5
k					
002 000			Ø.745 <sup>+.000</sup> 002		
			· · · · · · · · 002		4-
			××		
-	┫ 1.44				
	1.44				В
	SEC	CTION A-A	DETAIL	_ B	
			SCALE		
				.02 X .02 AROU SHAFT SQ. OR	ROUND
			<u>KX/XX</u>		
			.06	-	
					А
					A
DIMENSION	NOTES AND TOLERANCES: (UNLESS IS ARE IN INCHES FS. NOT SCALE FROM DI 1. INTERPRET DRAWING PER 2. REMOVE ALL SHARP EDC 3. DO NOT SCALE FROM DI	OTHERWISE SPECIFIED)	CALIFORNIA INSTITUTE OF TECHNOLOGY MASSACHUSETTS INSTITUTE OF TECHNOLO	PART NAME DOWEL INSTALLATION PUNCH, 3	
TOLERANC .XX ± .01 .XXX ± .00	4. ALL MACHINING FLUIDS AND FREE OF SULFUR, SILIC	MUSI BE FULLY SYNTHETIC, FULLY WATER SOLUBLE ONE, AND CHLORINE.	ADVANCED LIGO SEI	DESIGNER M.HILLARD 08 Feb. 2011 SIZE DWG. DRAFTER M.HILLARD 08 Feb. 2011 B	
ANGULAR:	C7	1500 32 μinch	NEXT ASSY	APPROVAL K.MASON 08 Feb. 2011 SCALE: 2:1	PROJECTION:
	5	4	3	2	1